Decoherence in Josephson Qubits from Dielectric Loss

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Dielectric loss from two-level states is shown to be a dominant decoherence source in superconducting quantum bits. Depending on the qubit design, dielectric loss from insulating materials or the tunnel junction can lead to short coherence times. We show that a variety of microwave and qubit measurements are well modeled by loss from resonant absorption of two-level defects. Our results demonstrate that this loss can be significantly reduced by using better dielectrics and fabricating junctions of small area \( \lesssim 10 \mu m^2 \). With a redesigned phase qubit employing low-loss dielectrics, the energy relaxation rate has been improved by a factor of 20, opening up the possibility of multiqubit gates and algorithms.

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Superconducting qubits are a promising candidate for the construction of a quantum computer [1]. Circuits work well, and experiments have demonstrated single qubit operations with reasonably long coherence times [2–6].

A recent experiment with phase qubits [7] has shown that the states of two qubits may be simultaneously measured, enabling full tomographic characterization of more complex gates [1]. Unfortunately, further progress in this system is hindered by short coherence times. Why is the coherence of phase qubits notably shorter than that of charge or flux qubits? Understanding this issue will aid progress in all superconducting qubits, as the identification of decoherence sources is crucial for continued improvements [8–10].

We report here a new decoherence mechanism, dielectric loss from two-level states (TLS). This loss is particularly important because of its surprisingly large magnitude; it can dominate all other sources of decoherence. We study the dielectric loss from bulk insulating materials as well as the tunnel barrier. A distinction is made between these two decoherence channels, even though their fundamental source is the same, because the losses manifest themselves differently.

This loss mechanism has been overlooked because it arises from a new class of decoherence: it is equivalent to dissipation from a fermionic bath [11], which gives qualitatively different behavior than the more familiar bosonic dissipation appropriate for photons or phonons. We present here several experimental measurements and a simple TLS model that provides a detailed description of this important phenomenon. Finally, by understanding this loss, we have obtained in a first-generation redesign of our phase qubit a 20-fold increase in coherence times, comparable to those of other successful devices.

Superconducting qubits are nonlinear microwave resonators formed by the Josephson inductance of a tunnel junction and its self-capacitance. Coherence is destroyed by loss and noise in these electrical elements. For capacitors, energy loss comes from dissipation in the insulator (with dielectric constant \( \epsilon \)), which is conventionally described by the loss tangent \( \tan \delta = \text{Im} \{ \epsilon \} / \text{Re} \{ \epsilon \} \). Small loss tangents \( \delta \lesssim 10^{-5} \) are desired, with the number of coherent oscillations in the qubit given by \( Q \sim 1/\delta \).

The loss tangent has generally been ignored because materials have been assumed to exhibit low loss at low temperatures. Indeed, we and others find that microwave loss is negligible for the crystalline substrates Si and Al2O3 [5,12]. However, crossover wiring in complex superconducting devices requires an insulating spacer that is typically made from amorphous SiO2 deposited by chemical vapor deposition (CVD). In Fig. 1 we present data showing the loss tangent of a microwave driven LC oscillator formed by a superconducting inductor and a 300 nm thick CVD SiO2 capacitor with \( C \sim 5 \) pF. Two small coupling capacitors connect the input and output ports. We measure the transmitted power as a function of frequency and drive amplitude in order to extract the loss tangent. At low temperature \( T = 25 \) mK \( \ll \hbar \omega / k \), where \( \omega / 2\pi \sim 6 \) GHz is the resonance frequency, we find that the loss varies strongly with drive amplitude and thus cannot be described as a conventional resistor (bosonic bath). The loss tangent is low at high amplitude, but scales inversely with the resonator voltage \( V^2 \) until it saturates at an intrinsic loss tangent \( \delta_i \approx 5 \times 10^{-3} \). Similar to high drive powers, high temperatures give lower loss (data not shown).

Conventional measurements at high temperature or power suggest low dielectric loss in CVD SiO2. However, superconducting qubits operate in the \( T, V \rightarrow 0 \) regime, where the intrinsic loss of SiO2 is largest. Hence, great care must be taken when choosing insulating dielectrics in any qubit design in order to prevent short coherence times.

Dielectric loss has been previously understood to arise from resonant absorption of microwave radiation by a bath
The power dependence of the loss arises from saturation of individual TLS, and for a parallel-plate geometry is given by

$$\delta = \frac{\pi \rho (ed)^2 \tanh(h \omega/2kT)}{3 \epsilon \sqrt{1 + \omega^2 T_1 T_2}},$$

where $x$ is the thickness, $\rho$ is the TLS density of states each having a fluctuating dipole moment $ed$ and relaxation times $T_1$ and $T_2$, and $\omega_R = (eVd/x)/h$ is the TLS Rabi frequency. This theory fits our data well with parameters compatible with previous measurements of bulk SiO$_2$ [13].

Tunnel junctions are similarly made from amorphous dielectric materials; are they also lossy? A key difference is that tunnel junctions have small volume, and the assumption of a continuous distribution of defects is incorrect. Instead, dielectric loss must be described by a sparse bath of discrete defects. Individual defects can be measured spectroscopically with the phase qubit [14,15], and in Fig. 2(a) we plot the peak value of the occupation probability of the qubit $|1\rangle$ state as a function of excitation frequency and qubit bias. Along with the expected bias dependence, the data also exhibit avoided two-level crossings (splittings) that arise from the qubit state resonating with individual TLS in the tunnel barrier. These data demonstrate the qualitative trend that small-area qubits show fewer splittings than do large-area qubits, although larger splittings are observed in the smaller junctions. The presence of these spurious resonances can be quantified by measuring the amplitude $S/h$ of each splitting, and then calculating the histogram of amplitudes. For clarity, this distribution is better analyzed through an integral of the number of splittings starting from the minimum experimental resolution of 0.01 GHz to $S'/h$ and normalized to a 1 GHz bandwidth. The averages of the corresponding integrals for seven large-area qubits and four small-area qubits are shown in Fig. 2(b). When plotted versus $\log(S')$, we find the data fall on a line with an abrupt cutoff at $S_{max}$, beyond which no further splittings are found. Furthermore, the slope of the line increases with qubit junction area $A$, and $S_{max}$ decreases with increasing $A$.

Although the splittings were initially understood as arising from TLS fluctuations of the critical current [14], we now believe that charge fluctuations better describe the data [16]. In this model, the interaction Hamiltonian between a TLS and the qubit is given by $H_{int} = (eVd/x) \times \cos \eta$, where $\eta$ is the relative angle of the dipole moment with respect to the electric field $V/x$. For a single TLS dipole with two configurations $L$ and $R$, the general Hamiltonian is

$$2H_{TLS} = \Delta(L|L\rangle - |R\rangle|R\rangle) + \Delta_0(|L\rangle|R\rangle + |R\rangle|L\rangle).$$

The eigenstates $|g\rangle = \sin(\theta/2)|L\rangle - \cos(\theta/2)|R\rangle$ and $|e\rangle = \cos(\theta/2)|L\rangle + \sin(\theta/2)|R\rangle$ have an energy difference $E = \sqrt{\Delta^2 + \Delta_0^2}$, where $\tan \theta = \Delta_0/\Delta$. For a phase qubit with capacitance $C$ and a transition energy $E_{10}$ between states $|1\rangle$ and $|0\rangle$, the effective interaction Hamiltonian is $H_{int} = \mu(S/2)(|1\rangle g\rangle - |0\rangle e\rangle - |0\rangle e\rangle - |1\rangle g\rangle)$ where $S$ gives the size of the splitting on resonance:

$$S = S_{max} \cos \eta \sin \theta,$$

$$S_{max} = \frac{2d}{x} \frac{e^2}{2C} E_{10}.$$

The expected distribution of the splitting sizes can be calculated by averaging the histogram of amplitudes. For clarity, this distribution is better analyzed through an integral of the number of splittings starting from the minimum experimental resolution of 0.01 GHz to $S'/h$ and normalized to a 1 GHz bandwidth. The averages of the corresponding integrals for seven large-area qubits and four small-area qubits are shown in Fig. 2(b). When plotted versus $\log(S')$, we find the data fall on a line with an abrupt cutoff at $S_{max}$, beyond which no further splittings are found. Furthermore, the slope of the line increases with qubit junction area $A$, and $S_{max}$ decreases with increasing $A$.
calculated using the standard TLS tunneling model, where \( \Delta \) is assumed to have a constant distribution and \( \Delta_0 \) has a distribution proportional to \( 1/\Delta_0 \) [17]. Changing the basis to more physical variables, the energy \( E \) and the dipole matrix element \( \sin \theta \) [see Eq. (2)], one finds the state density \( d^2N/dEdS \sin \theta \propto 1/\sin \theta \cos \theta \). An average over \( \eta \) yields
\[
\frac{d^2N}{dEdS} = \sigma A \sqrt{1 - S^2/S_{\text{max}}^2} \frac{1}{S}
\]  
(4)

for \( S < S_{\text{max}} \) and 0 otherwise, where \( \sigma \) is a materials constant describing the defect density.

This prediction is consistent with the measured splitting distributions of Fig. 2(b), where the integrated density of splittings \( dN/dE \) increases as \( \log S \) until reaching a cutoff at \( S_{\text{max}} \). In Fig. 2(b), the thick gray trace shows a good fit of the theory to the 13 \( \mu \)m\(^2\) data using parameters \( \sigma h = 0.5/\mu \)m\(^2\)GHz and \( S_{\text{max}}/h = 0.074 \) GHz. Although the relative slope of the 70 \( \mu \)m\(^2\) data scales slower than \( A \), Monte Carlo simulations confirm this arises from large resonances overlapping smaller ones, shadowing their presence. The arrows, which indicate the fitted values of \( S_{\text{max}} \), agree with the scaling \( 1/\sqrt{A} \) predicted by Eq. (3). The measured \( S_{\text{max}} \), along with the qubit capacitance and resonant frequency, yield a dipole moment with \( d/x \approx 0.06 \). This agrees with previous measurements [13,18,19] and makes physical sense since \( d \approx 0.13 \) nm corresponds to a single charge moving a distance of a single atomic bond. This numerical agreement strongly suggests that these junction resonances arise from charge TLS and not critical-current fluctuations.

To calculate decoherence from the resonances, we first introduce a new quantity: the average number of resonances that couple to the qubit. An estimate of this number comes from counting the resonances that fall within a frequency \( \pm S/2 \) of the qubit frequency:
\[
N_c = \int_{S_{\text{max}}}^{S_{\text{max}}} \frac{d^2N}{dEdS} dS \int_{E_{10}+S/2}^{E_{10}} dE \quad (5)
\]

\[
= (\pi/4)\sigma AS_{\text{max}} \quad (6)
\]

\[
= \sqrt{A/A_c}, \quad (7)
\]

where \( A_c \approx 90 \mu \)m\(^2\) for AlO\(_x\). Charge and flux qubits typically have \( N_c \ll 1 \), whereas for phase qubits \( N_c \sim 1 \).

For large-area junctions \( N_c \gg 1 \), the qubit couples to many junction resonances and the decay rate \( |1\rangle \rightarrow |0\rangle \) may be calculated using the Fermi golden rule:
\[
\Gamma_1 = \frac{2\pi}{\hbar} \int \frac{d^2N}{dEdS} (S/2)^2 dS \quad (8)
\]

\[
= (\pi/6)\sigma AS_{\text{max}}^2/\hbar \quad (9)
\]

\[
= \pi (\sigma/x)(e\hbar) E_{10}/3\epsilon \hbar \quad (10)
\]

This decay rate is equivalent to a dielectric loss tangent \( \delta_i = h\Gamma_1/E_{10} \) and corresponds to the \( T, V \rightarrow 0 \) limit of Eq. (1).

Using Eq. (9) and the values of \( \sigma \) and \( S_{\text{max}} \) determined in Fig. 2, we calculate a decay time \( 1/\Gamma_1 = 8 \) ns that agrees with the measured values 10–20 ns obtained for qubits with junction area 186 \( \mu \)m\(^2\). The tunnel barrier loss tangent is large \( \delta_i \approx 1.6 \times 10^{-3} \), comparable to that of CVD SiO\(_2\). This value is also reasonably consistent with a previous measurement of an AlO\(_x\) capacitor [20].

To understand decoherence for \( N_c \approx 1 \), we have performed Monte Carlo simulations of the interaction between the qubit and a collection of resonances randomly distributed according to Eq. (4). While the exact qubit dynamics depend upon the locations of the resonances, our simulations clearly show that the effects of dielectric loss may be statistically avoided by designing qubits with \( N_c \approx 1 \). With a junction bias that avoids resonances, decoherence is independent of time and the probability of decaying to the ground state has an average magnitude of \( N_c^2/2 \). Small decoherence is thus achieved by using small-area junctions or high-quality (small \( \sigma \) ) dielectrics for the tunnel barrier. Note that despite the good results that are currently obtained in small-area superconducting qubits, the conclusion that the tunnel junctions are of high quality is incorrect. The junction dielectric is actually quite lossy, but due to the small volume it is possible to statistically avoid the discrete nature of the loss.

We believe the large loss tangent of CVD SiO\(_2\) and AlO\(_x\) largely explains why only a few experiments have obtained long coherence times. For our phase qubits, junction loss plays a prominent role in limiting the coherence for the 186 \( \mu \)m\(^2\) junction. For our 70 \( \mu \)m\(^2\) device, loss from SiO\(_2\) is comparable to that from the junction itself, leading to nonexponential decay of the qubit state. For our 13 \( \mu \)m\(^2\) device, loss from SiO\(_2\) dominates since it contributes \( \sim 10\% \) to the qubit capacitance. The most successful experiments involving charge and flux qubits [3,4,21] have used small-area junctions and simple designs with no lossy dielectrics directly connected to the qubit junction, consistent with our observations. Given the generic need for wiring crossovers in advanced designs of a quantum computer, understanding dielectric loss is important for future success of all qubit technologies.

The defect density of TLS, as described by the loss tangent, determines the magnitude of decoherence. Is it possible to lower \( \delta_i \) by improving materials?

We suggest that OH defects are the dominant source of the TLS in our amorphous CVD SiO\(_2\) and AlO\(_x\) dielectrics. Previous experiments have measured the intrinsic loss in undoped and doped bulk quartz at 100 to 1000 ppm concentrations \( C_{\text{OH}} \). The loss tangent was found to scale roughly as \( \delta_i \approx 3.0 \times 10^{-5} + 0.4 C_{\text{OH}} \) [22]. The SiO\(_2\) studied in this experiment was deposited with plasma enhanced CVD techniques using SiH\(_4\) and O\(_2\) as precursor gases. A large concentration of OH is expected for these films, on the order of a few atomic percent [23]. The loss tangents we measure correlate with \( C_{\text{OH}} \) determined from
infrared spectroscopy and agrees in magnitude with an extrapolation of the bulk quartz data. We also note that a previous study measured $C_{OH}$ in amorphous AlO$_x$ to be as high as 2–8% [24]; this suggests why the loss tangent of AlO$_x$ is similar to that of CVD SiO$_2$.

In Fig. 1 we also show dielectric loss from CVD silicon nitride, made from precursor gases containing no oxygen. The intrinsic loss tangent was measured to be about 30 times smaller than for SiO$_2$, again confirming the importance of reducing the OH concentration.

With SiN$_x$ identified as a superior dielectric, the role of dielectric loss in phase qubits can be tested. In Fig. 3 we present Rabi oscillation data for two phase qubits, both with 13 $\mu$m$^2$ area but with different wiring designs. The top trace corresponds to our previous design with SiO$_2$, replaced with SiN$_x$ and a reduction of the total amount of dielectric. The coherence time of the new device is about 20 times longer than previously attained, with Rabi oscillations still visible after 1 $\mu$s. This success gives compelling evidence that dielectric loss plays a major role in phase qubit decoherence and defines a clear direction for improvements in materials.

In conclusion, we have experimentally identified dielectric loss from two-level states as an important source of decoherence in superconducting qubits. Our results clearly point toward a need for a more in-depth understanding of dissipation due to TLS because it increases as $T, V \to 0$, unlike conventional bosonic dissipation channels, and can hence lead to unexpected results. Given our observations, we are optimistic that new circuits and materials can be further developed to significantly improve the performance of all superconducting qubits.

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